

Docket No.: 50432-067

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :
Kai YANG, et al. :
Serial No.: : Group Art Unit:
Filed: March 27, 2001 : Examiner:
For: STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS

PRELIMINARY AMENDMENT

Commissioner for Patents
Washington, DC 20231

Sir:

Prior to examination of the above-referenced application, please amend the application as follows:

IN THE TITLE:

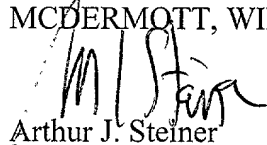
Please change the title from "DAMASCENE PROCESSING USING DIELECTRIC BARRIER FILMS" to --STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS--.

REMARKS

Entry of this preliminary amendment is respectfully requested.

Respectfully submitted,

MCDERMOTT, WILL & EMERY



Arthur J. Steiner
Registration No. 26,106

600 13th Street, N.W.
Washington, DC 20005-3096
(202) 756-8000 AJS:klm
Date: March 27, 2001
Facsimile: (202) 756-8087